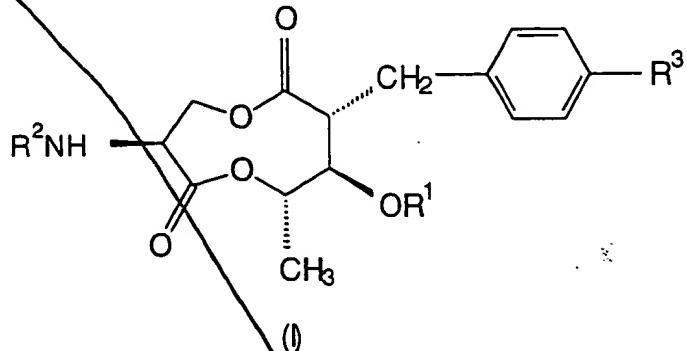


Please amend claims 1, 2, 9, 10 and 12-15 as follows:

1. (Amended) A compound represented by formula (I) or a salt thereof:



wherein

A2
 R^1 represents isobutyryl, tigloyl, isovaleryl, or 2-methylbutanoyl;

R^2 represents a hydrogen atom, an aromatic carboxylic acid residue excluding a 3-hydroxypicolinic acid residue, a 3-hydroxy-4-methoxypicolinic acid residue and a 3,4-dimethoxypicolinic acid residue, or represents a protective group of amino; and

R^3 represents a hydrogen atom.

2. (Amended) The compound or salt thereof according to claim 1, wherein the aromatic carboxylic acid residue represented by R^2 is selected from the group consisting of a benzoic acid residue having a substituent, a nicotinic acid residue having a substituent, a quinolinecarboxylic acid residue having a substituent, a ~~pyrimidine~~ carboxylic acid residue having a substituent, and a quinoxalinecarboxylic acid residue having a substituent.

A3
9. (Amended) The compound or salt thereof according to claim 20 or 21, wherein the acylamino represented by R^3 is C_{1-6} acylamino or the N,N -dialkylamino represented by R^3 is N,N -di(C_{1-4})alkylamino.

*AB
anc*
10. (Amended) The compound or salt thereof according to claim 20 or 21, wherein the acylamino represented by R^3 is formylamino or the N,N-dialkylamino represented by R^3 is N,N-dimethylamino.

AC
12. (Amended) A method for preventing the appearance and proliferation of fungi or exterminating fungi, comprising using the compound or salt thereof according to any one of claims 1, 20 or 21.

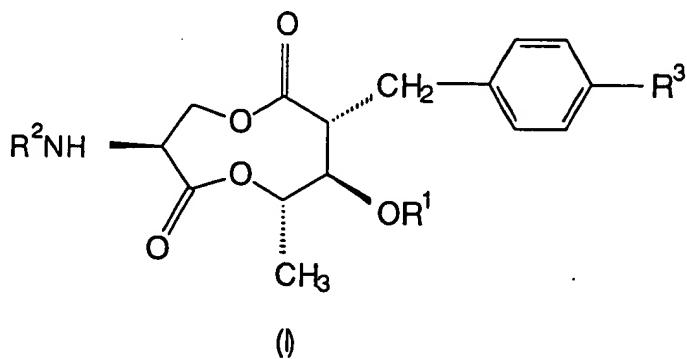
AC
Sub B3
13. (Amended) A method for treating fungal infectious diseases, comprising administering the compound or salt thereof according to any one of claims 1, 20 or 21 to animals including human beings.

14. (Amended) A method for treating fungal infectious diseases, comprising applying the compound or salt thereof according to any one of claims 1, 20 or 21 to agricultural or garden plants.

15. (Amended) A method for preventing the appearance and proliferation of fungi or exterminating fungi, comprising applying the compound or salt thereof according to any one of claims 1, 20 or 21 to industrial products or in the course of production of industrial products.

Please add new claims 20-28 as follows:

20. (New) A compound represented by formula (I) or a salt thereof:



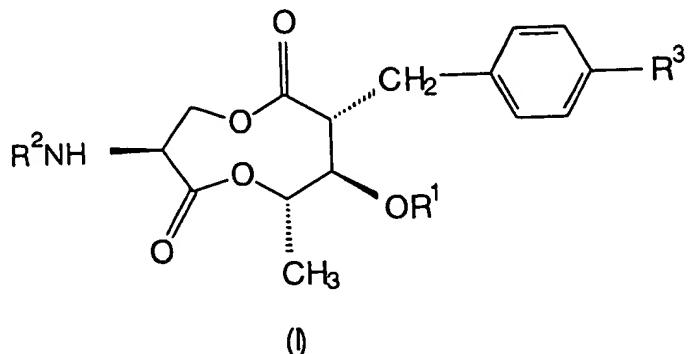
wherein

R^1 represents isobutyryl, tigloyl, isovaleryl, or 2-methylbutanoyl;

R^2 represents a 3-hydroxy-4-methoxypicolinic acid residue; and

R^3 represents nitro, amino, acylamino, or N,N-dialkylamino.

21. (New) A compound represented by formula (I) or a salt thereof:



wherein

R^1 represents isobutyryl, tigloyl, isovaleryl, or 2-methylbutanoyl;

R^2 represents a hydrogen atom, an aromatic carboxylic acid residue excluding a 3-hydroxy-4-methoxypicolinic acid residue, or represents a protective group of amino; and

R^3 represents nitro, amino, acylamino, or N,N-dialkylamino.

Sub B

22. (New) The compound or salt thereof according to claim 21, wherein the aromatic carboxylic acid residue represented by R^2 is selected from the group consisting of a benzoic acid residue having a substituent, a nicotinic acid residue having a substituent, a quinolinecarboxylic acid residue having a substituent, a pyrimidine carboxylic acid residue having a substituent, and a quinoxalinecarboxylic acid residue having a substituent.

AS
23. (New) The compound or salt thereof according to claim 21, wherein the aromatic carboxylic acid residue represented by R^2 is selected from the group consisting of a hydroxybenzoic acid residue, a picolinic acid residue, a nicotinic acid residue having a hydroxy substituent, a quinolincarboxylic acid residue, a pyrimidincarboxylic acid residue having a hydroxy substituent, and a quinoxalincarboxylic acid residue having a hydroxy substituent.

24. (New) The compound or salt thereof according to claim 21, wherein the aromatic carboxylic acid residue represented by R^2 is a picolinic acid residue,

said picolinic acid residue being substituted by at least one substituent selected from the group consisting of hydroxy, C_{1-6} alkoxy, benzyloxy, C_{1-6} alkylcarbonyloxy, benzyloxy, C_{1-6} alkoxy carbonyloxy, C_{1-6} alkyloxycarbonyl C_{1-10} alkylcarbonyloxy, benzyloxycarbonyl C_{1-10} alkylcarbonyloxy, carboxy C_{1-10} alkylcarbonyloxy, C_{1-6} alkylphosphoryloxy, di(C_{1-6})alkylphosphoryloxy, and diphenylphosphoryloxy.

25. (New) The compound or salt thereof according to claim 21, wherein the aromatic carboxylic acid residue represented by R^2 is a picolinic acid residue,

said picolinic acid residue being substituted

by C_{1-6} alkoxy and

by at least one substituent selected from the group consisting of hydroxy, C_{1-6} alkylcarbonyloxy, benzyloxy, C_{1-6} alkoxy carbonyloxy, C_{1-6} alkyloxycarbonyl C_{1-10} alkylcarbonyloxy, benzyloxycarbonyl C_{1-10} alkylcarbonyloxy, carboxy C_{1-10} alkylcarbonyloxy, C_{1-6} alkylphosphoryloxy, di(C_{1-6})alkylphosphoryloxy, and diphenylphosphoryloxy.

26. (New) The compound or salt thereof according to claim 21, wherein the aromatic carboxylic acid residue represented by R^2 is a picolinic acid residue,

the 4-position of said picolinic acid residue being substituted by C_{1-6} alkoxy,